

EMERGING NANOPATTERNING METHODS, NaPa

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Emerging nanopatterning methods (NaPa) is an Integrated Project in the NMP priority under Framework Programme 6. The patterning methods addressed in the project are nanoimprinting lithography, soft lithography, self-assembly and MEMS based methods. The NaPa consortium consists of 35 groups in 14 countries, including laboratories both from academia and from industry. Further information about the project can be found in:

http://dbs.cordis.lu/cordis-cgi/srchidadb?ACTION=D&SESSION=&DOC=1&TBL=EN_RTDN&RCN=EN_RCN_ID:1680&CALLER=CORDISwireSearch

In this presentation we will describe the structure and goals of the NaPa project.